

10/032049

METHODS FOR PLANARIZATION OF METAL-CONTAINING SURFACES
USING HALOGENS AND HALIDE SALTS

5

Abstract of the Disclosure

A planarization method includes providing a metal-containing surface (preferably, a Group VIII metal-containing surface, and more preferably a platinum-containing surface) and positioning it for contact with a polishing surface in the presence of a planarization composition that includes a halogen and a halide salt.

10

10032049-123101

"EXPRESS MAIL" MAILING LABEL NUMBER EL88827058545

DATE OF DEPOSIT: 21 December 2001
I HEREBY CERTIFY THAT THIS PAPER OR FEE IS BEING DEPOSITED WITH THE
UNITED STATES POSTAL SERVICE "EXPRESS MAIL POST OFFICE TO ADDRESSEE"
SERVICE UNDER 37 CFR 1.10 ON THE DATE INDICATED ABOVE AND IS ADDRESSED TO
THE ASSISTANT COMMISSIONER FOR PATENTS, BOX PATENT APPLICATION,
WASHINGTON, D.C. 20231

PRINTED NAME JACQUELYN K. TORBORG

SIGNATURE Jacquelyn K. Torborg